We investigate the modification of the electronic band structure in wurtzite GaN due to biaxial strain within the $M$ plane using photoreflectance (PR) spectroscopy. The compressively strained $M$-plane GaN film is grown on $\gamma$-LiAlO$_2$ (100). In the PR measurements, the electric-field vector ($\mathbf{E}$) of the probe light is polarized parallel (\|) and perpendicular (\perp) to the $c$ axis of GaN which lies in the growth plane. For $\mathbf{E} \parallel c$, the spectrum exhibits only a single resonant feature at lower energies, while for $\mathbf{E} \perp c$ a different single resonant feature appears at higher energies. To identify these features, we calculate the strain dependence of the interband transition energies and the components of the oscillator strength using the $\mathbf{k} \cdot \mathbf{p}$ perturbation approach. Comparison with the calculations shows that the origin of the PR features and their significant in-plane polarization anisotropy is related to the influence of $M$-plane, biaxial compressive strain on the valence-band structure of GaN. We estimate the value of the deformation potential $D_3$ to be $-4.7$ eV.

DOI: 10.1103/PhysRevB.65.075202 PACS number(s): 71.20.Nr, 71.70.Fk, 78.66Fd, 78.40.Fy

I. INTRODUCTION

The wurtzite (WZ) structure of III-V nitrides leads to electrostatic fields due to spontaneous and piezoelectric polarization, when the film growth is along the [0001] direction, i.e., for $C$-plane-oriented films.\(^1\) These electrostatic fields separate the electron and hole envelope wave functions in a heterostructure such as a quantum well. The consequent reduction in the envelope wave-function overlap results in a lower radiative efficiency for light-emitting devices.\(^2\) A way to overcome this problem is to grow films along nonpolar directions such as [1100], i.e., $M$-plane-oriented films. The growth of $M$-plane GaN films has been a challenge due to the lack of substrates that favor such orientation during film growth. Recently, the growth of $M$-plane-oriented films on $\gamma$-LiAlO$_2$ (100) substrates was demonstrated.\(^3\) It was experimentally shown that the electrostatic fields can be avoided in such nitride quantum wells.\(^4\) However, the lattice mismatch between the film and the substrate results in in-plane strain, which can strongly influence the electronic band structure (EBS) of the material.

EBS modification due to biaxial strain in the $C$ plane ($x$-$y$ plane) of WZ-GaN has been studied extensively both theoretically and experimentally.\(^5\) Isotropic strain in the $C$ plane (with strain components $\epsilon_{xx}=\epsilon_{yy}$) preserves the symmetry in the $x$-$y$ plane of the WZ-GaN lattice so that no significant in-plane optical polarization anisotropy occurs. For anisotropic strain in the $C$ plane, an in-plane polarization anisotropy can arise, which has been confirmed experimentally.\(^6\) The situation is expected to be quite different for an $M$-plane sample, where the unique $c$ axis lies within the growth plane. Here, even in the absence of in-plane strain, one expects to see an in-plane polarization anisotropy. Any biaxial strain within the $M$ plane ($x$-$z$ plane) further lifts the symmetry in the $x$-$y$ plane of the WZ-GaN lattice. According to theoretical predictions,\(^7,8\) biaxial strain within the $M$ plane would significantly modify the top two valence-band (VB) states. While in the absence of any strain these VB states have wave functions with nearly identical symmetry, this is no longer true in the presence of biaxial strain in the $M$ plane. This change in symmetry affects the polarization selection rules for interband transitions. Therefore, additional changes are expected in the polarization properties of an $M$-plane GaN film due to in-plane strain. However, to the best of our knowledge, so far there exists no direct experimental evidence for the EBS modification and the consequent changes in the optical polarization properties of GaN due to biaxial strain in the $M$ plane.

In this paper, we use photoreflectance (PR) spectroscopy to study the EBS modification of an $M$-plane GaN film due to in-plane biaxial compressive strain. The resonant features observed in the PR spectrum have different energies from those expected for unstrained GaN and show strong in-plane polarization anisotropy. We perform a $\mathbf{k} \cdot \mathbf{p}$ perturbation-based EBS calculation and determine the strain dependence of the energy of the three interband transitions at the fundamental band gap of GaN as well as the components of their oscillator strength. By comparison with the calculated EBS results, we identify the origin of the PR features and explain their polarization properties.

The paper is organized in the following way. In Sec. II, we present the sample structure and the PR setup. In Sec. III, we describe in detail the EBS calculation. In Sec. IV, we present the experimental results. The comparison of the experimental results with the EBS calculations and a discussion of the results are presented in Sec. V. Finally, we give a brief summary of the investigation in Sec. VI.

II. EXPERIMENTAL DETAILS

The $M$-plane GaN film (1.22 $\mu$m thick) used in this study was grown by rf plasma-assisted molecular-beam epitaxy (MBE) on a $\gamma$-LiAlO$_2$ (100) substrate.\(^3\) High-resolution triple-axis x-ray diffraction (XRD) and Raman spectroscopy were used to verify the $M$-plane orientation of the film and its single phase nature (i.e., absence of $C$-plane-oriented domains).\(^3\) Figure 1 shows the XRD profile across the (1100)
reflection of the sample. The inset displays the wurtzite-GaN unit cell and the choice of coordinates. The angular position of the (1100) reflection corresponds to a biaxial compressive strain in the M-plane with an out-of-plane dilatation $\epsilon_{z} = 0.29\%$. This result is in agreement with Raman measurements, which exhibit strongly blueshifted lines. Note that compressive strain is to be expected both from the lattice mismatch ($-0.3\%$ along $z$, $-1.7\%$ along $x$) between GaN(1100) and LiAlO$_2$(100) and from the thermal mismatch, which is compressive along both directions as well. For comparison, a C-plane GaN film, which is not expected to show any in-plane polarization anisotropy, was also studied to rule out spurious sources of polarization anisotropy. This C-plane GaN film was grown by reactive MBE on a 6H-SiC (0001) substrate$^1$ and is under biaxial tensile strain with an out-of-plane contraction $\epsilon_{z} = -0.08\%$.

Modulation spectroscopy techniques such as PR are usually the preferred method for the study of the EBS of semiconductors.$^{10}$ The PR technique is relatively insensitive to defects, has high-temperature capability, and reveals transitions at energies higher than the fundamental gap. In the PR measurements, we used a He-Cd laser ($3.815\text{ eV}$) as the pump beam. The probe beam (angle of incidence $\sim 10^\circ$) was usually obtained by dispersing the output of a Xe lamp using a 0.64 m monochromator (energy-band pass $\approx 4$ meV) and linearly polarizing the output beam with a Glan-Taylor prism. The electric-field vector ($\mathbf{E}$) of the probe beam was usually polarized parallel ($\parallel$) or perpendicular ($\perp$) to the $c$ axis. A second 1.0 m monochromator running synchronously with the first was used as a narrow-band pass filter in front of the UV-enhanced silicon detector. This setup helps to reduce the background signal and noise arising from the scattered pump beam and photoluminescence (PL) emission at low temperatures. Phase sensitive detection was performed using a lock-in amplifier.

III. ELECTRONIC BAND-STRUCTURE CALCULATIONS

In unstrained WZ-GaN, there are three closely spaced top VB’s at the Brillouin-zone center (wave vector $\mathbf{k} = 0$), $\Gamma_g$, $\Gamma_{upper}$, and $\Gamma_{lower}$ labeled here as heavy hole (HH), light hole (LH), and spin-orbit crystal-field split-off hole (SCH), respectively. The excitons involving electrons in the conduction band (CB) and holes in the HH, LH, and SCH bands are referred to as A, B, and C excitons, respectively. The states at the CB bottom have atomic $s$ orbital character. The top HH and LH band states have essentially atomic $p_z$ and $p_y$ orbital character (wave function $|X \pm iY\rangle$-like), while the SCH band states have $p_z$ orbital character (wave function $|Z\rangle$-like). The $c$ axis defines the $z$ direction. Due to strain, the VB states are strongly modified affecting both the energies as well as the polarization selection rules for the transitions. To theoretically estimate the strain-induced EBS modification at $\mathbf{k} = 0$, we adopt the $\mathbf{k} \cdot \mathbf{p}$ perturbation approach outlined by Bir and Pikus.$^{11}$ Since the large band gap of GaN reduces the interband action between the VB and the CB states,$^{12}$ the Hamiltonian for the strain dependence of the VB can be separately given by the following $6 \times 6$ matrix:

$$
H^v = \begin{bmatrix}
F & 0 & -H^* & 0 & K^* & 0 \\
0 & G & \Delta & -H^* & 0 & K^* \\
-H & \Delta & \lambda & 0 & I^* & 0 \\
0 & -H & 0 & \lambda & \Delta & I^* \\
K & 0 & I & \Delta & G & 0 \\
0 & K & 0 & I & 0 & F
\end{bmatrix},
$$

where

$$
F = \Delta_1 + \Delta_2 + \lambda + \theta, \quad G = \Delta_1 - \Delta_2 + \lambda + \theta,
$$

$$
H = i(A_6 k_x k_x + A_7 k_y + D_b \epsilon_{x+}),
$$

$$
I = i(A_6 k_y k_x - A_7 k_y + D_b \epsilon_{x+}),
$$

$$
K = A_5 k_1^2 + D_5 \epsilon_{z+}, \quad \Delta = \sqrt{2} \Delta_3,
$$

$$
\lambda = A_1 k_2^2 + A_2 k_1^2 + D_1 (\epsilon_{x+} + \epsilon_{y+}) + D_2 (\epsilon_{xz} + \epsilon_{yz}),
$$

$$
\theta = A_3 k_2^2 + A_4 k_1^2 + D_3 (\epsilon_{x+} + \epsilon_{y+}) + D_4 (\epsilon_{xz} + \epsilon_{yz}),
$$

$$
\epsilon_{x+} = \epsilon_{yx} - \epsilon_{xx} + 2i \epsilon_{xy}, \quad \epsilon_{z+} = \epsilon_{xz} + i \epsilon_{yz},
$$

$$
k_+ = k_x + i k_y, \quad k_1^2 = k_2^2 + k_3^2.
$$

The parameters $D_j$ ($j = 1$ to 6) denote the deformation potentials for the VB, and $A_j$ ($j = 1$ to 7) are equivalent to the Luttinger parameters and determine the hole effective masses. $\epsilon_{mn}$ and $k_1 (l,m = x,y,z)$ are the strain and wave-vector components, respectively. $\Delta_1$ is the crystal-field energy parameter, while $\Delta_2$ and $\Delta_3$ are spin-orbit energy parameters. The basis functions used to obtain $H^v$ are ($1/\sqrt{2}$)$|X \pm iY, \alpha \rangle$, ($1/\sqrt{2}$)$|X \pm iY, \beta \rangle$, $|Z, \alpha \rangle$, $|Z, \beta \rangle$, ($1/\sqrt{2}$)$|X - iY, \alpha \rangle$, and ($1/\sqrt{2}$)$|X - iY, \beta \rangle$. Here $|X \rangle$, $|Y \rangle$, and $|Z \rangle$ have symmetry properties of the atomic $p_x$, $p_y$, and $p_z$ orbital functions under the operations of the $C_{6v}$ group. $|\alpha \rangle$ and $|\beta \rangle$ denote the spin-wave functions corresponding to spin up and spin down. The diagonalization of the above matrix yields three distinct VB maxima with energies $E^v_j$. 075202-2
The Hamiltonian for the strain dependence of the CB minimum is given by a diagonal \(2 \times 2\) matrix with basis functions \(|S, \alpha\rangle\) and \(|S, \beta\rangle\). Its single distinct eigenvalue can be expressed as

\[
E^i = \alpha_i \epsilon_{zz} + \alpha_{zz} (\epsilon_{xx} + \epsilon_{yy}) + \frac{\hbar^2 k_z^2}{2m_e} + \frac{\hbar^2 k_y^2}{2m^*},
\]

where \(\alpha\) and \(m^*\) denote the CB deformation potential and the electron effective mass, respectively. The excitonic transition energies are then given by

\[
E_j = E^a + E^e - E^j - E^b,
\]

where \(E^a = E_{cx} + \Delta_1 + \Delta_2 = 3.532\) eV. The band gap \(E_g\) was chosen such that the A-exciton transition energy in unstrained GaN is 3.479 eV in the low-temperature limit as observed in experiments on free standing GaN.\(^{13}\) \(E^b\) denotes the exciton binding energy and is taken to be 26 meV for all three transitions.

The components of the oscillator strengths for the transitions, which determine the polarization selection rules, are obtained from momentum matrix elements of the type \(\langle \Psi_{CB}^l | p_x | \Psi_{VB}^l \rangle^2\) with \(l = x, y, z\). Here, \(\langle \Psi_{CB}^l \rangle = \langle S \rangle\) and \(\langle \Psi_{VB}^l \rangle = a_1 \langle X \rangle + a_2 \langle Y \rangle + a_3 \langle Z \rangle\) represent the orbital part of the CB and VB basis functions, respectively. The coefficients \(a_j\) are obtained by determining the eigenvectors of \(H^e\). The relative values of \(|\langle S | p_x | X \rangle|^2\), \(|\langle S | p_x | Y \rangle|^2\), and \(|\langle S | p_x | Z \rangle|^2\) were taken to be equal, in accordance with earlier theoretical results.\(^{14}\)

The relation between the in-plane and the out-of-plane strain components, which are needed for the calculations, can be obtained as follows. An \(M\)-plane film, under in-plane biaxial strain, is free to expand or contract in the out-of-plane direction. This implies that the out-of-plane stress component \(\sigma_{yy} = 0\) and leads to the following relation between the strain components:

\[
\epsilon_{yy} = -\frac{C_{12}}{C_{11}} \epsilon_{xx} - \frac{C_{13}}{C_{11}} \epsilon_{zz}, \quad \epsilon_{xy} = \epsilon_{yz} = \epsilon_{xz} = 0,
\]

where \(C_{ij}\) are the elastic stiffness constants.\(^{15}\)

Since we are interested in the transition energies only at \(k = 0\), the number of required parameters \((\alpha, \Delta_1, \Delta_2, \alpha)\) is actually smaller. We estimate the required parameters by combining two previously reported experimental and theoretical results of strain dependent studies on C-plane GaN as follows. For GaN under isotropic biaxial strain in the C plane, it is possible to write a simplified analytical expression for the strain dependence of the three excitonic transition energies. Fitting these expressions to a set of experimental data, Shikanai \textit{et al.}\(^{16}\) estimated \(\Delta_1 = 52\) meV, \(\Delta_2 = 5\) meV, and derived the following relations:

\[
\Xi = \left( \frac{D_1 - C_{13}^3}{C_{13}} \right) \frac{D_2}{38.9 \text{ eV}}, \quad \left( \frac{D_3 - C_{13}^3}{C_{13}} \right) = 23.6 \text{ eV}.
\]

\(\Xi\) denotes the combined dilatational component of the deformation potential acting on the CB, which for a C-plane sample with \(\epsilon_{xx} = \epsilon_{yy}\) can be expressed as

\[
\Xi = \alpha \frac{C_{33}}{C_{13}} \alpha_{zz}.
\]

The local atomic coordination of the WZ structure is the same as that for the cubic zinc-blende structure and differs only for the relative positions of the third-nearest neighbors and beyond. This justifies a quasicubic approximation,\(^{11}\) which relates some of the required parameters to each other and has been verified by first-principles EBS calculations.\(^{12}\)

Of interest to us here are the relations

\[
2D_4 = -D_3, \quad D_1 - D_2 = -D_3, \quad \alpha\Delta_1 = \alpha\Delta_2 = \alpha, \quad \Delta_1 = \Delta_2.
\]

Using Eq. (5b) and Eq. (7a), we can determine \(D_3\) and \(D_4\).

To determine \(D_1\), \(D_2\), and \(D_3\), different assumptions have been made previously.\(^{7,17}\) Shikanai \textit{et al.}\(^{16}\) found that their experimentally determined \(D_3^}\text{exp} and \(D_4^}\text{exp}\) values differed from the theoretically estimated values \(D_3^}\text{theory} and \(D_4^}\text{theory}\) of Suzuki and Uenoyma.\(^{5,18}\) Both ratios \(D_3^}\text{exp}/D_3^}\text{theory} and \(D_4^}\text{exp}/D_4^}\text{theory} have a value of about 2.7. We obtain \(D_1\) and \(D_2\) by multiplying the values of these parameters as obtained by Suzuki and Uenoyma by a factor of 2.7. In this way, Eq. (7b) continues to be satisfied as were Suzuki and Uenoyma original values. The initial value of \(D_3\) is also obtained in this fashion, and then slightly adjusted (\(\sim 15\%\)) to fit our experimental results. Finally, we estimate \(\alpha\) by combining Eq. (5a), Eq. (6), Eq. (7c), and the \(D_j\) values. The deformation-potential parameter values thus obtained are \(\alpha_\Delta = \alpha = 44.5\) eV, \(D_1 = -41.4\) eV, \(D_2 = -33.3\) eV, \(D_3 = 8.2\) eV, \(D_4 = -4.1\) eV, and \(D_5 = -4.7\) eV. The resulting interband hydrostatic deformation potentials \(\alpha\Delta_1 = 4.1\) eV and \(\alpha\Delta_2 = 11.2\) eV are comparable in magnitude to previously reported values listed in Refs. 5 and 19. The above parameters reproduce very well the experimentally observed EBS modification of GaN under isotropic biaxial \(C\)-plane strain as reported by Shikanai \textit{et al.}\(^{16}\) Two earlier experimental studies\(^{3,20}\) on C-plane GaN with anisotropic in-plane strain had reported \(D_3\) values to be \(-2.4\) eV and \(-3.3\) eV, while the closest theoretical estimate\(^{21}\) for its value is \(-4.0\) eV.

\(M\)-plane strain leads to significant changes in the original VB states so that it is no longer possible to describe the transitions in terms of A-, B-, and C-exciton transitions of unstrained GaN. We have adopted the nomenclature \(E_1\), \(E_2\), and \(E_3\) for the three \((n = 1)\) exciton transitions representing increasing energy. Figure 2(a) shows the variation of these three calculated transition energies with isotropic biaxial \(M\)-plane strain \((\epsilon_{xx} = \epsilon_{yy})\). The dashed lines reveal two anticrossings. Figures 2(b)–2(d) show the \(x, y,\) and \(z\) components of the oscillator strengths of the three transitions. These re-
The situation is reversed for tensile stress along $x$ where strain continues to show a significant in-plane polarization and only relative shifts between the VB states were calculated (i.e., setting $D_1$ and $D_2=0$). Here, we estimate the absolute transition energies for direct comparison with experiments by determining all relevant deformation potentials.

The C-plane GaN films are mostly grown on substrates with similar hexagonal symmetry, which leads to isotropic in-plane strain ($\epsilon_{xx} = \epsilon_{zz}$). However, due to the inherent lower symmetry of the M plane, a GaN film with an M-plane orientation is likely to experience anisotropic in-plane strain. We therefore extended our calculation to arbitrary in-plane strain in the range $|\epsilon_{xx}|$ and $|\epsilon_{zz}|\approx 0.6\%$. The variation of the $E_1$, $E_2$, and $E_3$ transition energies with in-plane strain is shown by the contour plots in Figs. 3(a)–3(c). Figure 3(d) displays the difference $E_1 - E_2$. For $\epsilon_{xx}\approx 0.04\%$ and $\epsilon_{zz}\approx -0.24\%$, the difference $E_1 - E_2 \approx 0$. By comparison with a similar calculation for C-plane strain (not shown here), we identify this strain coordinate to correspond to a zinc-blende-like situation, where the in-plane strain counteracts the crystal-field splitting such that the top two VB states are degenerate at $k=0$. Therefore, for example, with a strain variation along $\epsilon_{xx}=-0.1833\epsilon_{zz}$ [dashed line in Fig. 3(d)], we will encounter only one apparent anticrossing between the three transition energies, just as in the case of C-plane strain with $\epsilon_{xx} = \epsilon_{yy}$.

The relative values of the $x$, $y$, and $z$ components of the oscillator strengths for the three transitions are shown by the gray-scale contour plots in Fig. 4 for M-plane strain in the range $|\epsilon_{xx}|$ and $|\epsilon_{zz}|\approx 0.6\%$. For future reference, we note that these plots show that for $\epsilon_{xx}$ and $\epsilon_{zz}\lessgtr -0.2\%$, the $E_1$, $E_2$, $E_3$ transitions are predominantly $x$, $y$, and $z$ polarized, respectively.
$E_2$, and $E_3$ transitions are predominantly $x$ polarized, $z$ polarized, and $y$ polarized, respectively.

**IV. EXPERIMENTAL RESULTS**

Figure 5(a) shows the PR spectra of the $M$-plane sample for $E \parallel c$ and $E \parallel c$ recorded at 295 and 5 K. The schematic inset shows the measurement geometry, with $\phi$ being the in-plane polarization angle relative to the $c$ axis. When the polarization of the light is rotated by $90^\circ$ from $E \parallel c$ (i.e., $E \parallel x$, $\phi=90^\circ$) to $E \parallel c$ (i.e., $E \parallel z$, $\phi=0^\circ$) in the $M$ plane, we find that the spectrum is shifted to higher energies. For each polarization, the spectrum consists of a single resonant feature. To determine the corresponding transition energy, we fit these features by Aspnes' line-shape function with redefined parameters.$^{24,25}$

$$\frac{\Delta R}{R}(E) = \text{Re} \left[ \frac{a \kappa_3(c_1 \gamma)^m e^{i(\delta + [m-3] \pi/2)}}{(E-E_j+i\kappa_1 \gamma)^m} \right].$$

With the exponent $m=3$, the generalized Lorentzian function above mimics the first derivative Gaussian-broadened excitonic transition line shape.$^{26}$ The fitting parameters $E_j$, $\gamma$, $a$, and $\delta$ denote the transition energy, broadening parameter, amplitude, and phase factor, respectively. $\kappa_1 = 0.364m - 0.147$ and $\kappa_2 = -0.115m + 1.7$ are constants. The transition energies obtained from fitting are 3.428 eV (3.498 eV) for $E \parallel c$ and 3.468 eV (3.546 eV) for $E \parallel c$ at 295 K (5 K). The error is 3 meV for all values. Thus, the effective band gap of the $M$-plane film increases by 40 meV (48 meV) at 295 K (5 K), when the in-plane polarization of the probe light is rotated by $90^\circ$ from $E \parallel c$ to $E \parallel c$.

Since the PR spectrum of the $M$-plane sample depends critically on the polarization angle $\phi$, we have to verify that the angular alignment is correct. If the spectra shown in Fig. 5(a) are indeed for properly aligned $E \parallel c$ and $E \parallel c$ situations, they represent the only two possible independent line shapes. Therefore, for any other $\phi$, the line shape can be approximated by a linear combination of the type

$$\frac{\Delta R}{R}(E, \phi) = \frac{\Delta R_\parallel}{R_\parallel}(E) \cos^2(\phi) + \frac{\Delta R_\perp}{R_\perp}(E) \sin^2(\phi),$$

where $\Delta R_\parallel / R_\parallel$ ($\Delta R_\perp / R_\perp$) represents the line shape measured for $\phi=0^\circ$ ($\phi=90^\circ$) with the assumption $R_\parallel R_\perp$. To test this, we fix the probe beam energy at 3.45 eV (295 K), where $\Delta R_\parallel / R_\parallel = 2.3 \times 10^{-4}$ and $\Delta R_\perp / R_\perp = -2.25 \times 10^{-4}$. We then calculate the signal strength for any other $\phi$ using Eq. (9). The circles in Fig. 5(b) show a polar plot of the measured $|\Delta R/R|$, which agrees very well with the calculated variation shown by the solid line. This angular dependence of the PR signal also demonstrates the lower symmetry (twofold rotation) of the $M$-plane GaN film.

To rule out the possibility that these polarization characteristics arise from other sources, we studied a $C$-plane GaN sample, where we did not find any significant in-plane polarization anisotropy as expected. Normally, when PR measurements are used for characterization of III-V semiconductors...
and alloys with (001) zinc-blende or C-plane wurtzite structures, the polarization of the probe beam is not an issue. However, with M-plane wurtzite nitrides, using an unpolarized probe beam or one that is polarized at an angle different from $\phi=0^\circ$ or $90^\circ$, the resulting spectrum would be a weighted sum of the two spectra for $\phi=0^\circ$ and $90^\circ$. From such an arbitrary resultant line shape, no meaningful EBS parameter can be extracted. In fact, a spectrum measured with $\phi=45^\circ$ at 295 K (not shown here) gave a transition energy value equal to 3.483 eV, which is quite different from and even larger than the actual values of $E_1$ and $E_2$.

V. DISCUSSION

The XRD measurements show that the M-plane film is under biaxial compressive strain. Keeping this in mind and comparing the PR results with the calculated oscillator strength components in Fig. 4, we identify the lowest-energy PR feature seen for $E \parallel c$ (i.e., $E \parallel |x|$) as the $E_1$ transition associated with a predominantly $|X|$-like VB. The high energy PR feature, seen for $E \parallel c$ (i.e., $E \parallel |z|$), is identified as the $E_2$ transition associated with a predominantly $|Z|$-like VB. The in-plane strain components $\varepsilon_{xx}$ and $\varepsilon_{zz}$ of the sample are those for which $E_1=3.498$ eV in Fig. 3(a) and $E_2=3.546$ eV in Fig. 3(b). The out-of-plane dilatation $\varepsilon_{yy}$, which is then obtained using Eq. (4), is matched to the experimental value $\varepsilon_{yy}=0.29\%$ by varying the deformation potential $D_5$, resulting in $\varepsilon_{xx}=-0.56\%$ and $\varepsilon_{zz}=-0.31\%$.

For a Gaussian-broadened excitonic transition, the product of the amplitude and square of the broadening parameter ($a \gamma^2$) in Eq. (8) is proportional to the oscillator strength. For the $x$-polarized $E_1$ and $z$-polarized $E_2$ transitions, the parameters obtained are approximately the same. The calculated relative $x$ and $z$ components of the oscillator strength of the $E_1$ and $E_2$ transitions, respectively, are both about 0.97 for $\varepsilon_{xx}=-0.56\%$ and $\varepsilon_{zz}=-0.31\%$. These two facts together suggest that the theoretical result of Suzuki and Unuyama, which predicted $|\langle S| p_x |X \rangle|^2 = |\langle S| p_z |Z \rangle|^2$, is correct.

It is instructive to compare the present situation with unstained or compressively strained C-plane GaN ($\varepsilon_{xx}=\varepsilon_{yy}$) with regard to the polarization properties. In such cases, one expects to see two dominant transitions (A and B exciton) for $E \parallel c$ and one dominant transition (C exciton) for $E \parallel |c|$. In effect, a polarization-dependent effective band-gap change would occur with a value equal in magnitude to the difference between the lowest-energy A and the highest-energy C transition. However, to our best knowledge, this has never been observed experimentally, because it is difficult to get pure $E \parallel c$ polarization with a C-plane GaN film. With an M-plane film, both pure $E \parallel c$ and pure $E \parallel |c|$ polarizations are possible, but here we see only one PR feature for $E \parallel |c|$. At the same time, the energies of the features for both $E \parallel c$ and $E \parallel |c|$ are quite different from the ones expected for unstrained GaN. Thus, although a polarization-dependent effective band-gap change is in principle possible even in unstrained GaN, the energies together with the polarization properties of the PR features in the present sample can only be explained by including the effect of in-plane biaxial compressive strain. We therefore have direct experimental evidence for an M-plane strain-induced EBS modification in GaN. Note also that for unstrained GaN the effective band-gap change would involve the lowest- (A-exciton) and highest- (C-exciton) energy transitions, while here it involves the lowest- ($E_1$) and next-higher- ($E_2$) energy transition. Detection of the highest-energy $E_2$ transition involving the $|Y|$-like VB [expected at 3.58 eV in our sample as identified by the black spot in Fig. 3(c)] is not possible with PR, since a significant $E \parallel y$ polarization is not achievable with an M-plane film. In a polarized PL study of M-plane GaN grown on (1100) 6H-SiC, shifts in the emission-peak positions were also reported, but the shift was not attributed to a strain-induced EBS modification.

Gil and Alemu have also reported a theoretical study of the EBS modification due to biaxial strain in the M plane of GaN. They predicted that for large in-plane compressive strain with $E \parallel c$ (i.e., $E \parallel |x|$) both the lowest-energy (A-
exciton, according to their nomenclature) and the highest-energy (C-exciton) transitions would have significant oscillator strength. Their result differs from both of our results, namely, the theoretical calculations and experimental observations, since we do not observe the high-energy feature for E||c. However, it is likely that their choice of coordinates was different so that their M plane would correspond to the A plane in our case, which might be the cause for this discrepancy.

VI. SUMMARY

We have provided experimental evidence for the modification of the EBS of GaN due to biaxial strain in the M plane. We identified the PR features seen in the M-plane GaN sample for the two orthogonal polarizations E||c and E\perp c by comparing them with k·p EBS calculations. Their origin and the observed polarization properties were shown to be related to a modification of the VB of GaN due to in-plane compressive strain in the M plane. By matching the spectroscopically estimated strain to the value obtained from XRD measurements, we determined the deformation potential D\perp of GaN. The experimental results also support some of the earlier theoretical predictions regarding the influence of M-plane strain on the EBS of GaN. These results demonstrate the importance of the use of a properly polarized probe beam for postgrowth PR characterization of M-plane nitride layers.

ACKNOWLEDGMENTS

The authors would like to acknowledge the support of M. Ramsteiner, A. Thamm, U. Jahn, and L. Schrottke during the course of this work.

*Electronic address: htg@pdi-berlin.de